



**ALUPE UNIVERSITY**

**OFFICE OF THE DEPUTY VICE CHANCELLOR**

**ACADEMICS, RESEARCH AND STUDENTS AFFAIRS**

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**UNIVERSITY EXAMINATIONS**

**2024/2025 ACADEMIC YEAR**

**FOURTH YEAR FIRST SEMESTER REGULAR MAIN**  
**EXAMINATION**

**FOR THE DEGREE OF BACHELOR OF EDUCATION SCIENCE**

**COURSE CODE: PHY 425E**

**COURSE TITLE: THE PHYSICS OF SEMICONDUCTOR  
DEVICES**

**DATE: 9<sup>th</sup> January 2025**

**TIME: 1400 – 1700**

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**INSTRUCTION TO CANDIDATES**

- SEE INSIDE

**THIS PAPER CONSISTS OF 6 PRINTED PAGES**

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MAIN EXAMINATION

## PHY 425E: THE PHYSICS OF SEMICONDUCTOR DEVICES

STREAM: BED (SCIENCE)

DURATION: 3 Hours

INSTRUCTIONS TO CANDIDATES

a) Answer the **TWO** questions in **SECTION A** and any other **THREE** questions in **SECTION B**.

b) The following constants maybe useful

Boltzmann's constant	$k = 1.38 \times 10^{-23} \text{ J/K}$ or $8.62 \times 10^{-5} \text{ eV/K}$
Electronic charge	$e = 1.60 \times 10^{-19} \text{ C}$
Free electron rest mass	$m_o = 9.11 \times 10^{-31} \text{ Kg}$
Permeability of free space	$\mu_o = 4\pi \times 10^{-7} \text{ H/m}$
Permittivity of free space	$\epsilon_o = 8.85 \times 10^{-12} \text{ F/m}$ or $8.85 \times 10^{-14} \text{ F/cm}$
Dielectric constant of silicon	$\epsilon = 11.7$
Planck's constant	$h = 6.625 \times 10^{-34} \text{ J/s}$ or $\hbar = \frac{h}{2\pi} = 1.054 \times 10^{-34} \text{ J/s}$
Proton rest mass	$M = 1.67 \times 10^{-27} \text{ Kg}$
Density of states in silicon ( $T=300\text{K}$ ),	$(N_c = 2.8 \times 10^{19} \text{ cm}^{-3})$
Density of states in silicon ( $T=300\text{K}$ )	$(N_v = 1.04 \times 10^{19} \text{ cm}^{-3})$
$n_i$ , Silicon (300 K)	$n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$
$n_i$ , GaAs (300 K)	$n_i = 1.8 \times 10^6 \text{ cm}^{-3}$
$n_i$ , GaAs (400 K)	$n_i = 3.28 \times 10^9 \text{ cm}^{-3}$

**SECTION A (28 MARKS)****Question One (14 Marks)**

- a) Briefly describe the effect of adding acceptor impurity atoms in a semiconductor. (3 Marks)
- b) What is the meaning the following terms applicable to semiconductor physics course
- Acceptor level (1 Mark)
  - Donor level (1 Mark)
  - Mobility of the charge carrier (1 Mark)
  - Drift velocity (1 Mark)
- c) Draw a well labelled energy level diagram of p-type semiconductor and explain what happens to the charge carriers when  $T > 0$ . (4 Marks)
- d) A particular intrinsic semiconductor has resistivity of  $50 \Omega - cm$  at  $T = 300 K$  and  $5 \Omega - cm$  at  $T = 330 K$ . Determine the bandgap energy of the semiconductor in  $eV$  given

$$\text{that } \frac{E_g}{2k} \left( \frac{1}{T_1} - \frac{1}{T_2} \right) = \ln \frac{\sigma_2}{\sigma_1} + \frac{3}{2} \ln \frac{T_1}{T_2}. \quad (3 \text{ Marks})$$

**Question Two (14 Marks)**

- a) Draw a well labelled energy band diagram of reverse biased pn junction. (2 Marks)
- b) Sketch a well labelled energy-band diagram of the npn bipolar transistor under zero bias and under a forward-active mode bias. (4 Marks)
- c) Using band structure plot of GaAs, describe negative differential mobility in Gunn diode. (3 Marks)
- d) State any three advantages of light emitting diode. (3 Marks)
- e) Differentiate between Schottky junction and Ohmic junction (2 Marks)

**SECTION B (42 MARKS)****Question Three (14 Marks)**

- a) With help of a well labelled diagram, distinguish between direct and indirect bandgap semiconductor. (4 Marks)
- b) Given that  $n = N_C \exp\left[-\left(\frac{E_C - E_F}{kT}\right)\right]$  and  $p = N_V \exp\left[-\left(\frac{E_F - E_V}{kT}\right)\right]$ , deduce the expression of intrinsic carrier concentration,  $n_i$ . (4 Marks)
- c) Consider GaAs at  $T = 300 K$ .
- Determine  $p$ , if  $E_i - E_F = 0.35 eV$  (2 Marks)
  - Assuming that  $p$  from part (i) remains constant, determine value of  $E_i - E_F$ , when  $T = 400 K$ . (2 Marks)
  - Find value of  $n$  in both parts i) and part ii) (2 Marks)

**Question Four (14 Marks)**

- a) The conductivity versus temperature for typical n-type semiconductor is shown in Figure 1.

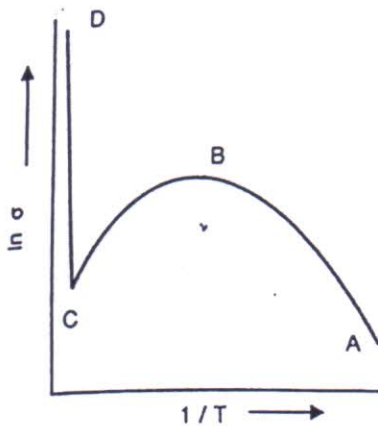


Figure 1

Briefly describe what happens in the following regions

- i) AB (2 Marks)
  - ii) BC (2 Marks)
  - iii) CD (1 Mark)
- b) Consider a germanium semiconductor at  $T = 300 K$ . Calculate the thermal equilibrium concentrations of  $n$  and  $p$  for  $N_d = 5 \times 10^{15} \text{ cm}^{-3}$  and  $N_a = 0$  (6 Marks)
- c) What is the difference between n-type compensated semiconductor, p-type compensated semiconductor and completely compensated semiconductor. (3 Marks)

**Question Five (14 Marks)**

a) The Hall effect apparatus are illustrated in Figure 2.

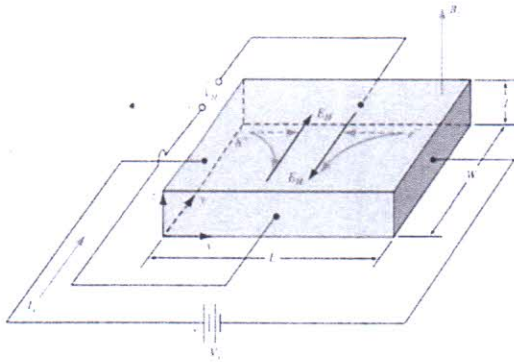


Figure 2

In steady state,  $qE_y = qv_x B_z$ . Deduce expressions of the following for n-type semiconductor.

- i) Hall voltage,  $V_H$  (4 Marks)
  - ii) The hole concentration,  $n$  (1 Mark)
  - iii) The hole mobility,  $\mu_n$  (3 Marks)
- b) Consider silicon at  $T = 300 K$ . A Hall effect device is fabricated with the following geometry:  $d = 0.005 \text{ cm}$ ,  $W = 0.05 \text{ cm}$ , and  $L = 0.5 \text{ cm}$ . The electrical parameters are:

$I_x = 0.5mA$ ,  $V_x = 1.25V$ , and  $B_z = 6.5 \times 10^{-2} Tesla$ . The Hall field is  $E_H = -16.5mV/cm$ .

Determine:

- i) the Hall voltage, (2 Marks)
- ii) the majority carrier concentration and (2 Marks)
- iii) the majority carrier mobility (2 Marks)

### Question Six (14 Marks)

- a) State any four assumptions in deriving the ideal diode equation. (4 Marks)
- b) A silicon pn junction at  $T = 300K$  with zero applied bias has doping concentrations of  $N_d = 5 \times 10^{16} cm^{-3}$  and  $N_a = 5 \times 10^{15} cm^{-3}$ . Given that

$$x_n = \left\{ \frac{2 \epsilon_s V_{bi}}{e} \left[ \frac{N_a}{N_d} \right] \left[ \frac{1}{N_a + N_d} \right] \right\}^{1/2} \quad \text{and} \quad W = \left\{ \frac{2 \epsilon_s V_{bi}}{e} \left[ \frac{N_a + N_d}{N_a N_d} \right] \right\}^{1/2}$$

Determine

- i)  $V_{bi}$  (2 Marks)
- ii)  $x_n$  (2 Marks)
- iii)  $W$  (2 Marks)
- iv)  $x_p$  (2 Marks)
- c) Using a well labelled energy-band diagram, show a pn junction in thermal equilibrium, when both the n and p regions are degenerately doped. (2 Marks)

### Question Seven (14 Marks)

- a) Highlight the four operating modes of transistors. (4 Marks)
- b) With the help of a well labelled diagram, explain the working mechanism of n-channel D-MOSFET in depletion mode. (4 Marks)

- c) A silicon npn bipolar transistor is uniformly doped and biased in the forward-active region. The neutral base width is  $x_B = 0.8 \mu\text{m}$ . The transistor doping concentrations in the emitter, base and collector are  $N_E = 5 \times 10^{17} \text{ cm}^{-3}$ ,  $N_B = 10^{16} \text{ cm}^{-3}$  and  $N_C = 10^{15} \text{ cm}^{-3}$ , respectively. Use ( $n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$ ). Calculate thermal-equilibrium minority carrier hole, electron and hole concentrations in the emitter, base and collector ( $p_{E0}$ ,  $n_{B0}$  and  $p_{C0}$ ) (6 Marks)

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